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Outstanding Reviewers for *Nanoscale Advances* in 2019

We would like to take this opportunity to thank all of *Nanoscale Advances*'s reviewers, and in particular highlight the Outstanding Reviewers for the journal in 2019, as selected by the editorial team for their significant contribution to *Nanoscale Advances*. We announce our Outstanding Reviewers annually and each receives a certificate to give recognition for their contribution. The reviewers have been chosen based on the number, timeliness and quality of the reports completed over the last 12 months.

A message from Professor Dirk Guldi, Editor-in-Chief:

Following recent years, *Nanoscale Advances* is, once again, recognizing the Outstanding Reviewers. Peer review is the essential tool to guarantee the quality and impact of *Nanoscale Advances*. Moreover, peer review depends on the excellence and timeliness of the reviews on top of the many demands that we face as active researchers. Carefully drafted reviews of work by our peers is at the

heart of the peer review process as it provides a valuable service to the scientific community, in general, and to the readers of *Nanoscale Advances*, in particular. I want to add my thanks to these Outstanding Reviewers and also thank everyone who has reviewed manuscripts for *Nanoscale Advances*.

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Dr Anna Rulka, Executive Editor